		1449 (Modified)	ICATIONS	ATTY. DOCKET NO. YOR920000344US1			SERIAL NO. 09/692606 (
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT					APPLICANT: Chu et al.					
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REFERE		DESIGNATION	U.S. I	PATE	NT DOCUMENTS					
EXAMINER INITIALS		DOCUMENT NUMBER	DATE		NAME	CLA	ss	SUBCLASS		G DATE PPRO.)
EK_	AA	5,906,951	May 1999	Chu et al.		438		751		
EX	AB	5,476,813	Dec. 1995	Naruse		438		311		
EK	AC	5,462,883	Oct. 1995	Dennard et al.		438		459		
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EK	AE.	5,298,452	Mar. 1994	Meyerson		437		81		
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EK.	AQ	T. Mizuno, "High I	Performance St	trained	l-Si p-MOSFET's on SiGe				s fabric	ated by
		SIMOX Technology", IEDM Tech. Digest 99-934, 1999.								
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.